



Attorney's Docket No.: 05542-149004 / 784C5

3723/#
#13 Amended
Smt

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Manoocher Birang et al.

Art Unit : 3723

Serial No. : 09/863,118

Examiner : David Q. Nguyen

Filed : May 22, 2001

Title : METHOD OF FORMING A TRANSPARENT WINDOW IN A POLISHING
PAD

Commissioner for Patents
Washington, D.C. 20231

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JAN 30 2003

RESPONSE

TECHNOLOGY CENTER R3700

In response to the action mailed September 18, 2002, please amend the application as follows:

In the claims:

Please amend claims 17, 23, 25, 27, 31, 38 and 39 as follows:

17. (Amended) A polishing pad for a chemical mechanical polishing apparatus, comprising:

an article having a polishing surface and a surface opposite the polishing surface for attachment to a platen;

a solid substantially transparent section formed in the polishing surface; and

an aperture formed in the surface opposite the polishing surface and aligned with the transparent section.

18. The polishing pad of claim 17, wherein the article includes a first layer with the polishing surface and a second layer adjacent to the first layer.

19. The polishing pad of claim 18, wherein the transparent section extends through the first layer.

CERTIFICATE OF MAILING BY FIRST CLASS MAIL

01/28/2003 JADD01 00000062 09863118

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I hereby certify under 37CFR §1.8(a) that this correspondence is being deposited with the United States Postal Service as first class mail with sufficient postage on the date indicated below and is addressed to the Commissioner for Patents, Washington, D.C. 20231.

Date of Deposit JANUARY 21, 2003

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